

Company Contact:

Adrian Kiermasz
Metryx, Limited
t: +44 (0)127 586 6260
e: adrian.kiermasz@metryx.net

Press Contact:

Dave Richardson
Impress Public Relations
t: +1-415-994-1423
e: dave@impress-pr.com

Metryx Enters Japanese Market in Cooperation with Canon Marketing Japan

BRISTOL, UK— May 5, 2007 — Metryx, Limited, a supplier of mass metrology equipment to the semiconductor manufacturing industry, today announced that it has signed a memorandum of understanding with Canon Marketing Japan (Canon MJ) to cooperatively market and promote Metryx' Mentor mass metrology products to leading Japanese semiconductor manufacturers.

Metryx' cooperation with Canon MJ is another significant step in the company's increasing focus on the Asia-Pacific region. Due to the growing acceptance and adoption of Mentor technology in the region, the company recently increased its own business development capabilities with the hiring of Gary Ditmer as Asia Business Director, based in Japan.

"Finding the right local partner in Japan is of paramount importance when entering the market," stated Adrian Kiermasz, President and CEO of Metryx. "Working in coordination with Canon MJ, we have established the best possible scenario. Along with our recent regional management hires, this is yet another key part of the puzzle we now have in place to give ourselves and our technology the best platform for successful adoption in the global chip manufacturing business."

"The Mentor technology has proven successful in advanced technology nodes in both 200 and 300mm production," said Gary Ditmer, Asia Business Director for Metryx. "Japan is home to a number of the industry's technology leaders, particularly in 300mm volume production, including logic, flash, and DRAM activities. Together with Canon MJ, we look forward to exploiting the opportunities that exist for our technology in Japan."

The Mentor's capabilities are proven for any device manufacturing process that involves a measurable mass change, including deposition, etch, and CMP processes; and has been implemented successfully for measurement of low-k, high-k gate and silicon etch applications. Mass metrology is performed on actual product wafers as there is absolutely no front side intervention or intrusions, enabling users to reduce the use of test wafers, improve cycle time and increase yield.

About Metryx

Metryx is a semiconductor equipment manufacturer specializing in unique nanotechnology mass measurement techniques. Based in Bristol, England, Metryx's non-destructive 200mm and 300mm metrology tools offer atomic layer accuracy making

them ideal for material characterization and device manufacture process control. For more information on the company and its products please visit www.metryx.net